

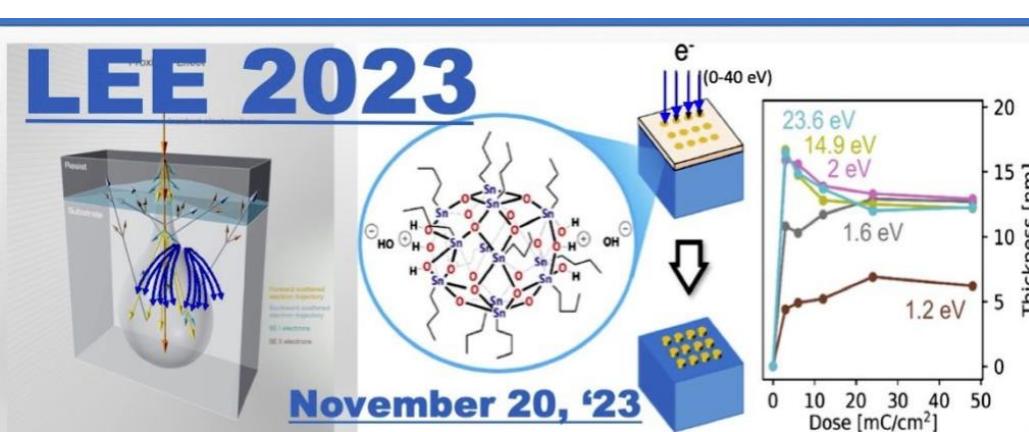


# Effect of secondary electrons emission in extreme-UV diamond detectors



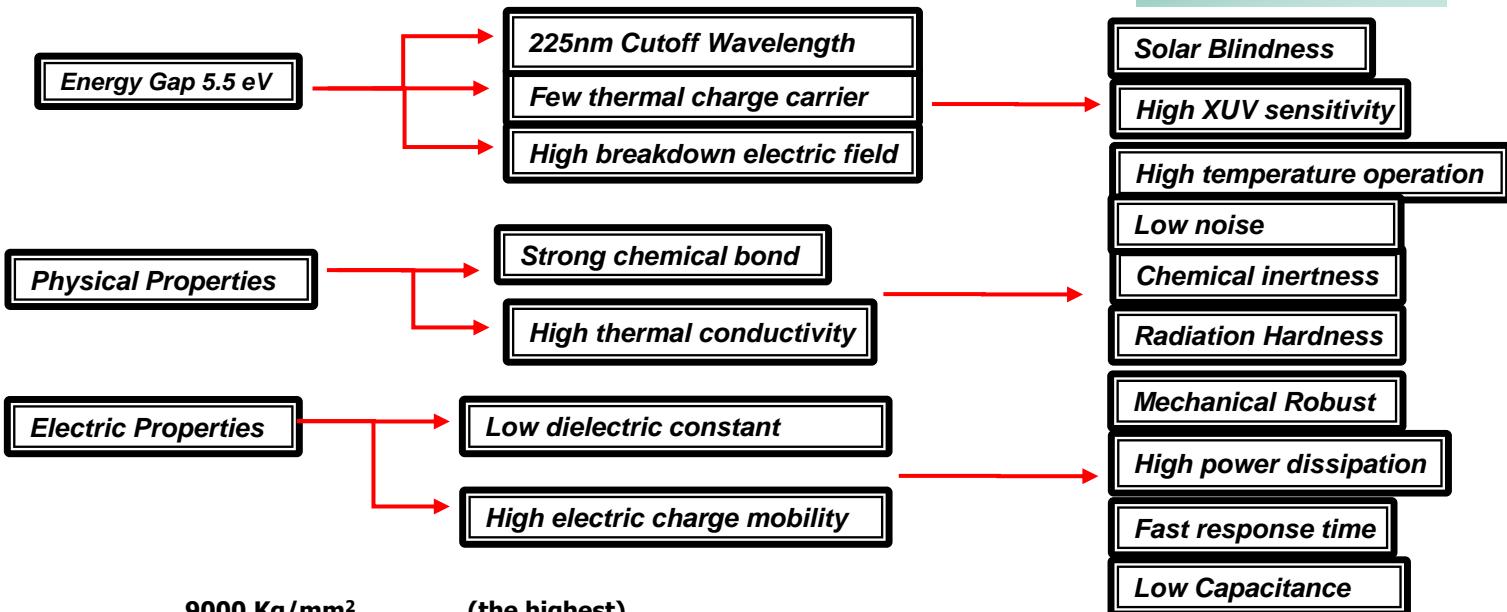
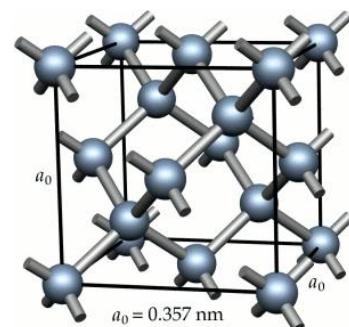
Prof. Claudio Verona

*Università di Roma "Tor Vergata", Italy*  
e-mail: [claudio.verona@uniroma2.it](mailto:claudio.verona@uniroma2.it)



Università di Roma "Tor Vergata", Italy

# Diamond properties



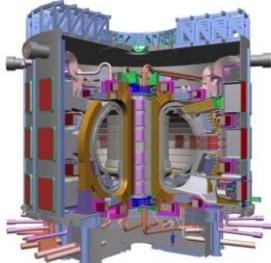
|  |                                    |                 |
|--|------------------------------------|-----------------|
| ▪ HARDNESS   | 9000 Kg/mm <sup>2</sup>            | (the highest)   |
| ▪ YOUNG'S MODULES                                    | 1012 N/m <sup>2</sup>              | (the strongest) |
| ▪ FRICTION   | 0.05                               | (the lowest)    |
| ▪ THERMAL CONDUCTIVITY                               | 20 W/cm K                          | (5 times Cu)    |
| ▪ ELECTRICAL RESISTIVITY                             | $10^{16} \Omega\text{cm}$          |                 |
| ▪ ELECTRICAL BREAKDOWN                               | $10^7 \text{ V/cm}$                | (30 times GaAs) |
| ▪ ELECTRON, HOLE MOBILITY >2000 cm <sup>2</sup> /V s |                                    |                 |
| ▪ OPTICAL ABSORPTION                                 | transparent from IR to IV (5.4 eV) |                 |
| ▪ MELTING POINT                                      | 3350 °C                            |                 |
| ▪ RADIATION HARDNESS                                 | very high                          |                 |
| ▪ CHEMICAL REACTIVITY                                | extremely low                      |                 |

## Diamond based UV detectors applications:

- ✓ Plasma diagnostic in fusion reactors
- ✓ Sun observation from satellite
- ✓ Synchrotron radiation detectors
- ✓ EUV spectroscopy



# *Plasma V-UV and soft X-ray diagnostic*

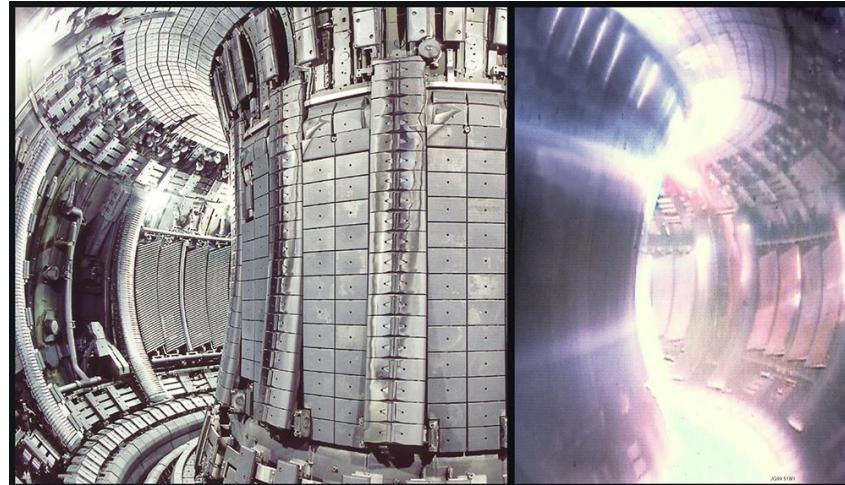


ITER fusion reactor



SPARC fusion reactor

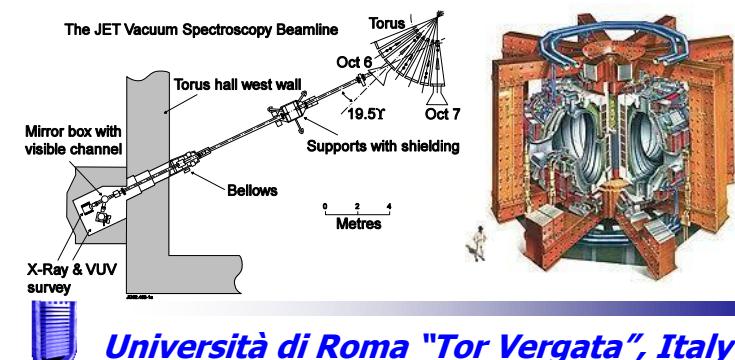
- ✓ Plasma temperature: (T) 100-200 million Kelvin
- ✓ Plasma density: (n)  $1-2 \times 10^{20}$  particles m<sup>-3</sup>
- ✓ Most relevant emission for plasma diagnostics in extreme-UV / soft-X ray spectral range



## Plasma diagnostic in Fusion reactors

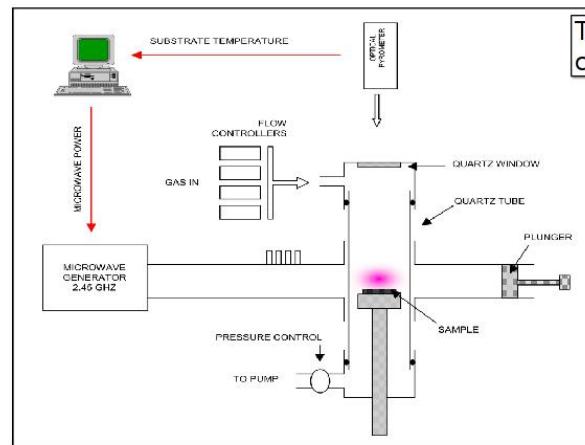
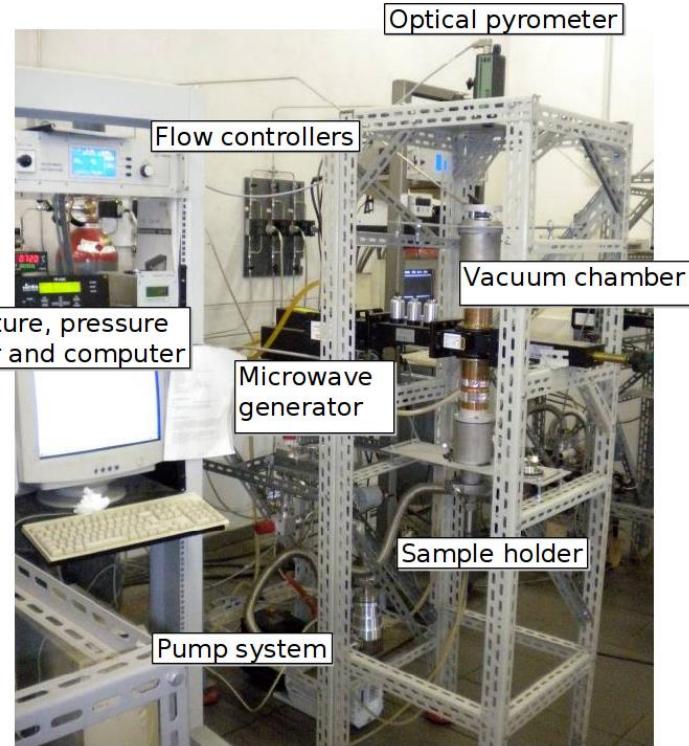
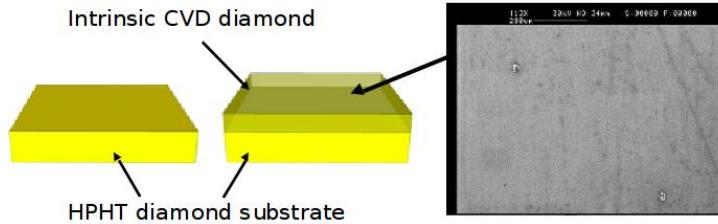
- temperature
- density
- particle and energy confinement timescale
- impurity dynamics
- atomic collision rates
- plasma-wall interaction
- plasma dynamics
- characterization of the electron fluid
- atomic structure of highly ionized atoms

CVD diamond detectors fabricated at Rome "Tor Vergata" University were permanently installed at Joint European Torus (JET), and currently used by plasma physics groups at JET to study impurity dynamics, to monitor the ELMs (Edge Localized Modes) and for MHD (MagnetoHydroDynamics) analysis.



Università di Roma "Tor Vergata", Italy

# *Single Crystal Diamond film synthesis*



## Doping

✓  $\text{B}_2\text{H}_6$  10-30 sccm

## Substrates

✓ (100) HPHT type Ib  $4 \times 4$  mm<sup>2</sup>

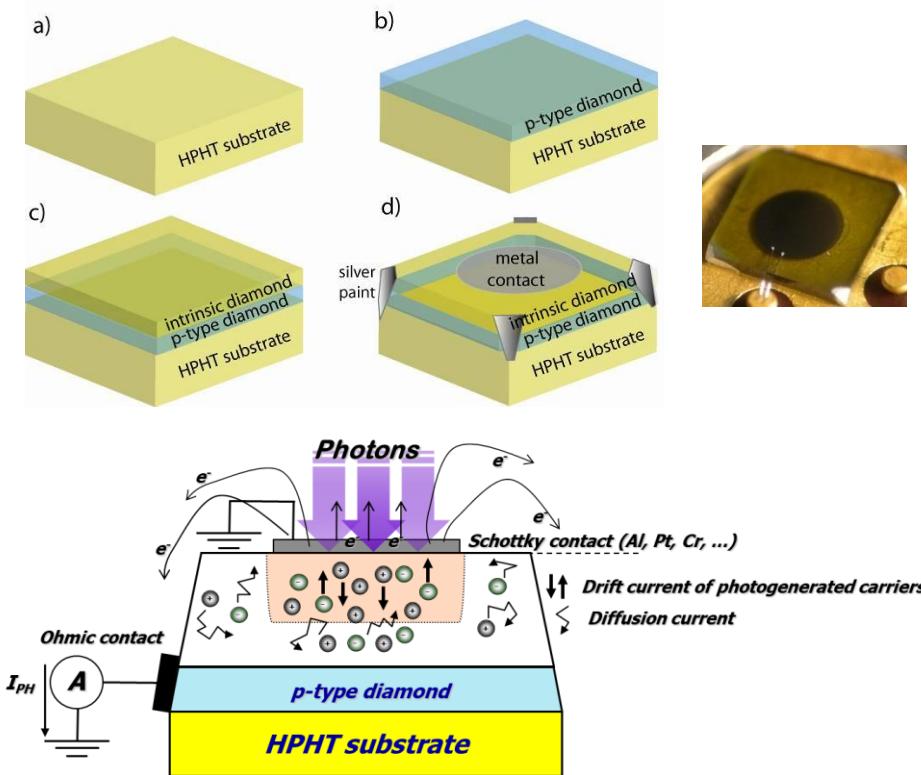
## Typical growth parameters

|                    |                                     |
|--------------------|-------------------------------------|
| Plasma composition | 99% $\text{H}_2$ - 1% $\text{CH}_4$ |
| Temperature        | 650 – 800 °C                        |
| Microwave power    | 500 - 600 W                         |
| Pressure           | 100 - 150 mbar                      |
| Gas flow rate      | 100 sccm                            |

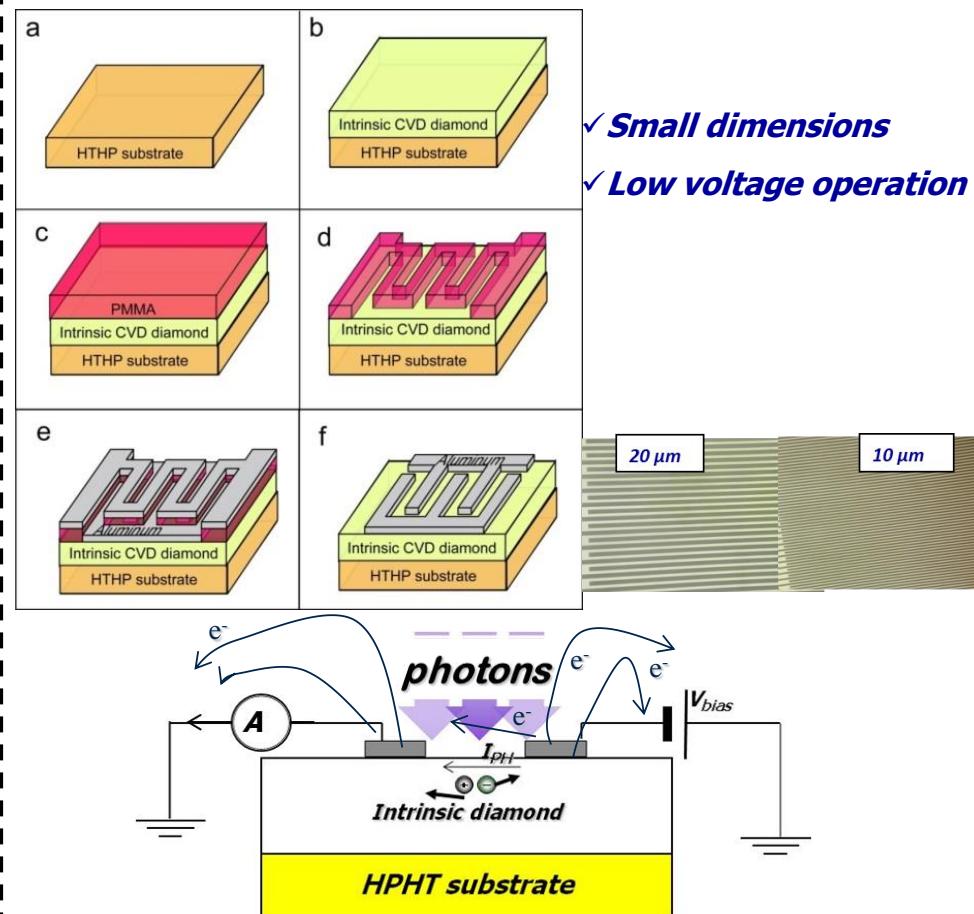


# Diamond based detectors

## Fabrication process of diamond detector operating in transverse configuration



## Fabrication process of diamond detector operating in planar configuration



# *Secondary electron emission current*

## Study of secondary emission current from the illuminated surfaces to the device response

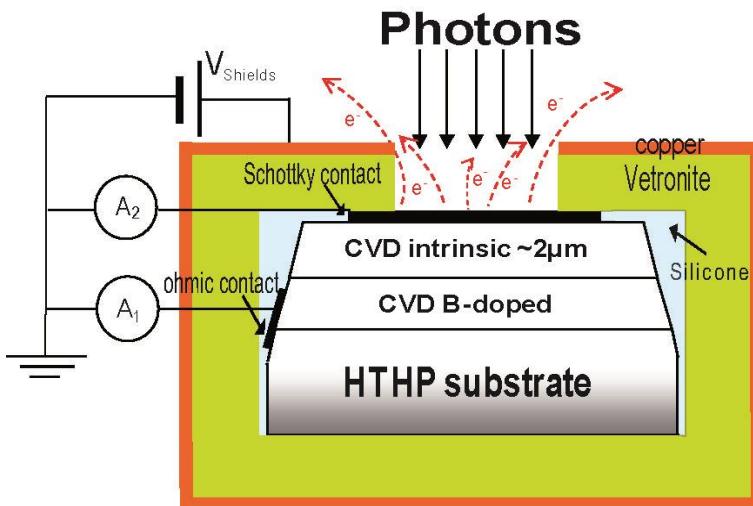
The secondary electron emission can depend on

- ✓ Environment conditions
  - ✓ External electric fields
  - ✓ Charging effects of insulating materials
  - ✓ Pressure, humidity
- ✓ Operating condition (applied voltage)
- ✓ Device geometry (transverse, planar)
- ✓ Wavelength

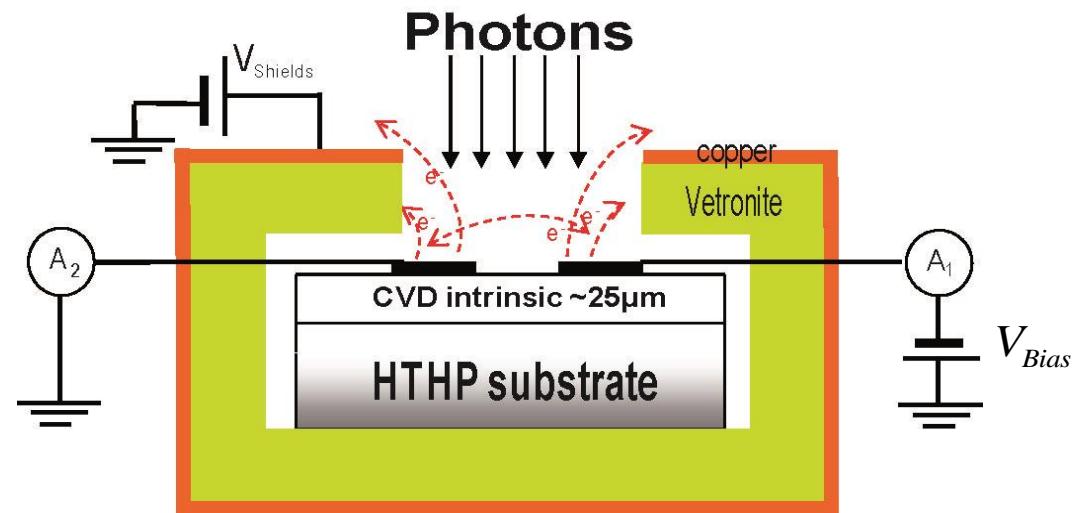
Such contribution must be taken into account in order to obtain a precise and reliable absolute calibration of the UV-based device.



# Experimental setup



P-type/intrinsic diamond/metal  
Schottky photodiodes

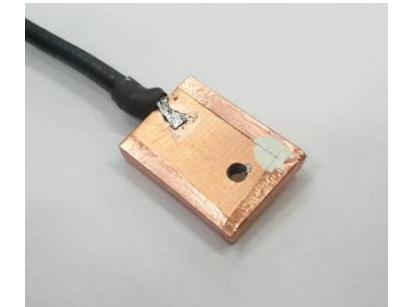


Photoconductive detector in planar  
configuration with interdigitated electrodes

Current simultaneously is measured by two electrometers ( $A_1$  and  $A_2$ )



$V_{\text{shield}}$

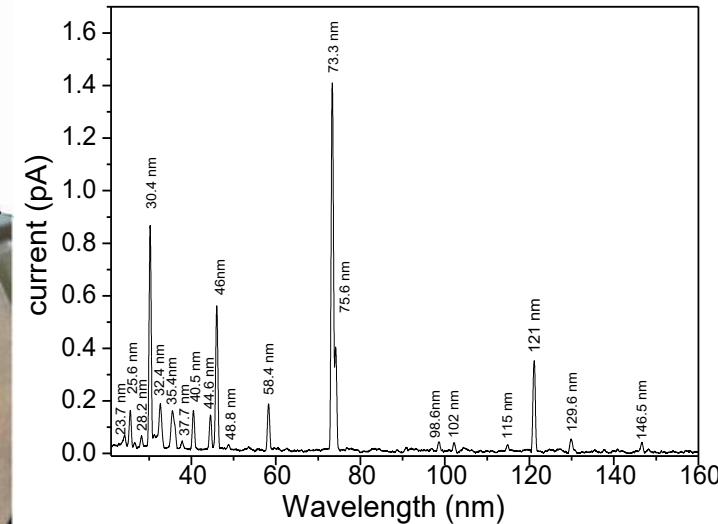
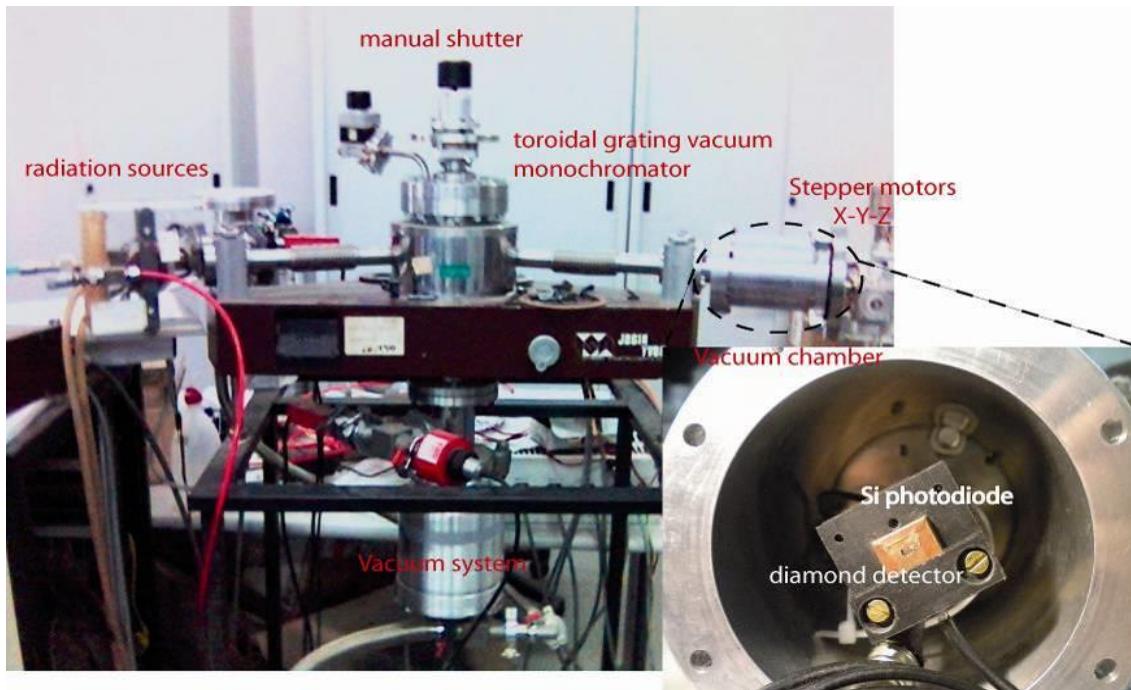


Keithley 6517b picoammeters (the internal voltage source was used as bias voltage for both devices).



Università di Roma "Tor Vergata", Italy

# Experimental setup

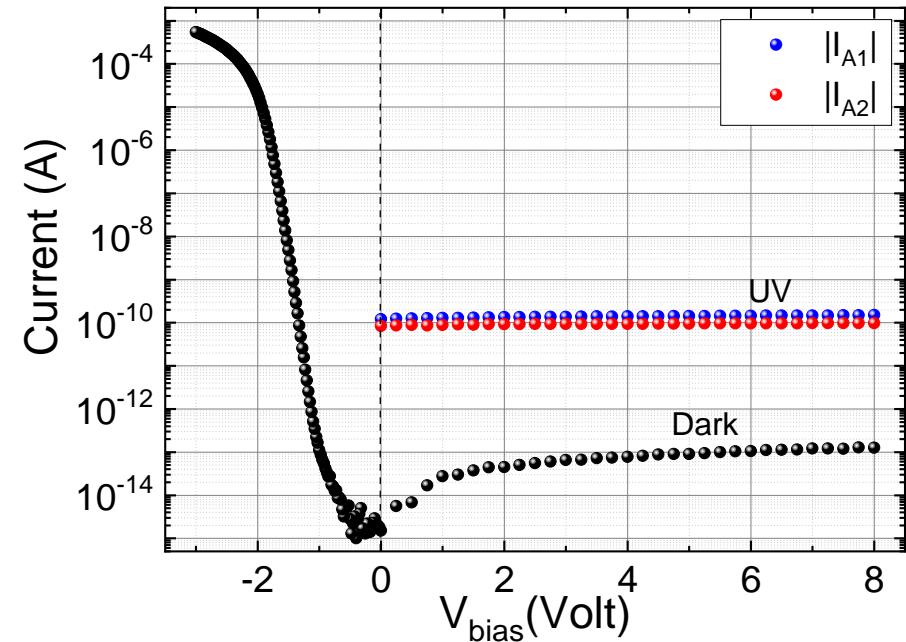
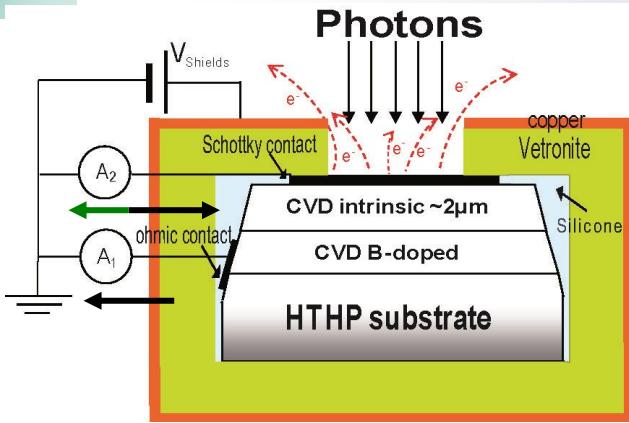


- EUV toroidal grating vacuum monochromator (5 Å wavelength resolution)
- DC He/Ne gas discharge radiation sources, spot size: 0.25×6.00 mm<sup>2</sup>, spectral range : 20 nm - 150 nm.
- Calibrated NIST AXUV Silicon photodiode for comparison.

The emission spectrum of a DC discharge He and He-Ne lamp measured in unbiased mode by the SCD detectors.

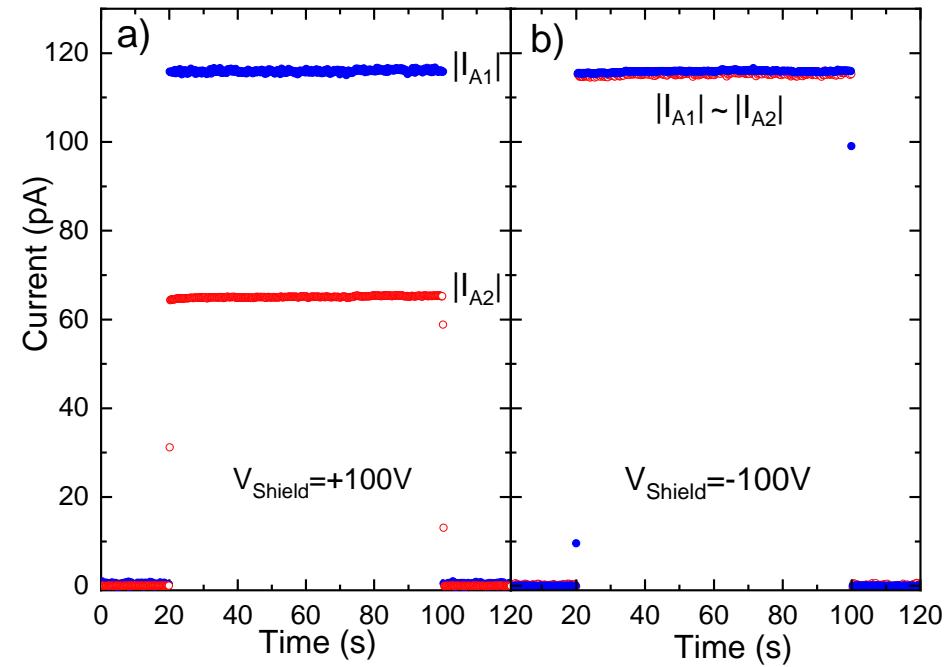


# Transverse configuration: Photocurrent

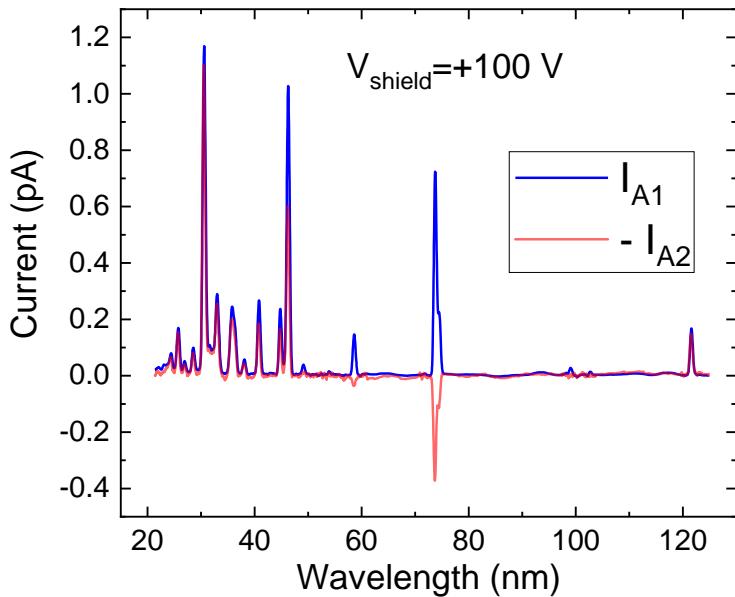
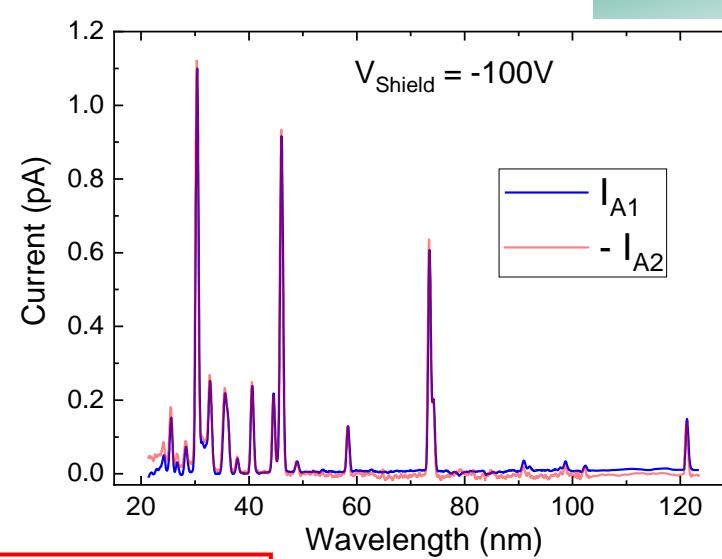
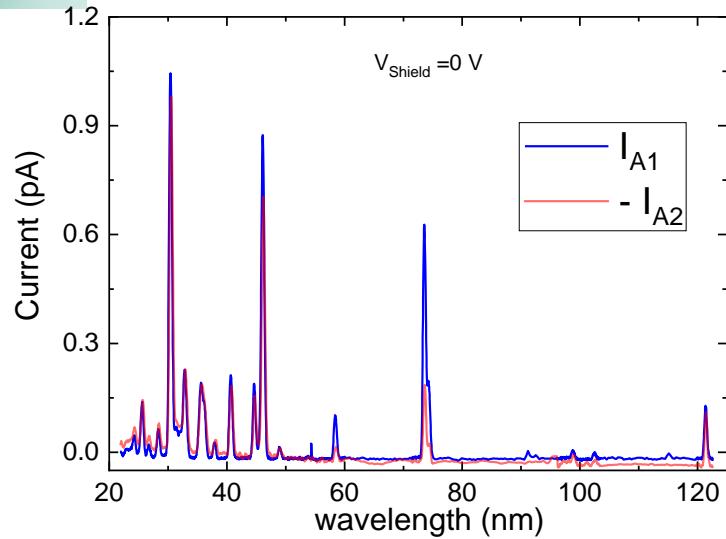


I-V characteristics in dark and under broadband UV irradiation

$$\begin{array}{ll} V_{shield} \gg 0 & V_{shield} \ll 0 \\ I_{A_1} = |I_{ph}| & I_{A_1} = |I_{ph}| \\ I_{A_2} = |I_e - I_{ph}| & I_{A_2} = |I_{ph}| \end{array}$$



# Transverse configuration: He-Ne spectra

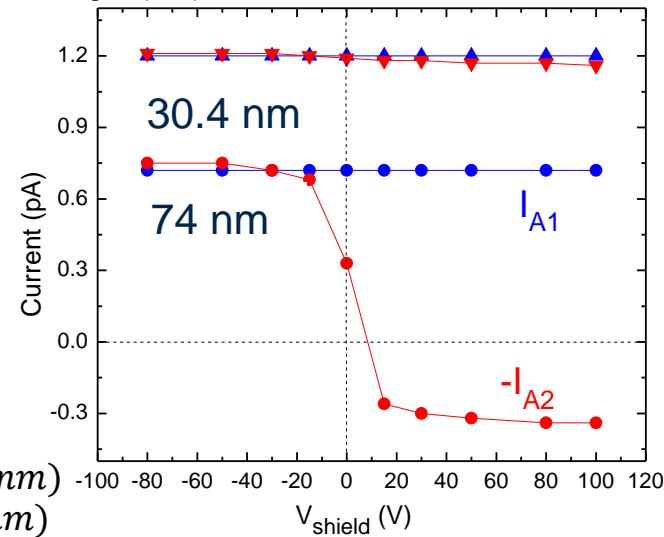


$$I_{A_1} = I_{ph}$$

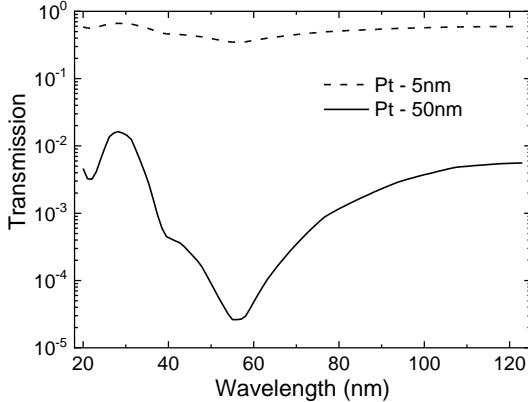
$$I_{A_2} = I_e - I_{ph}$$

$$I_e = I_{A_1} + I_{A_2}$$

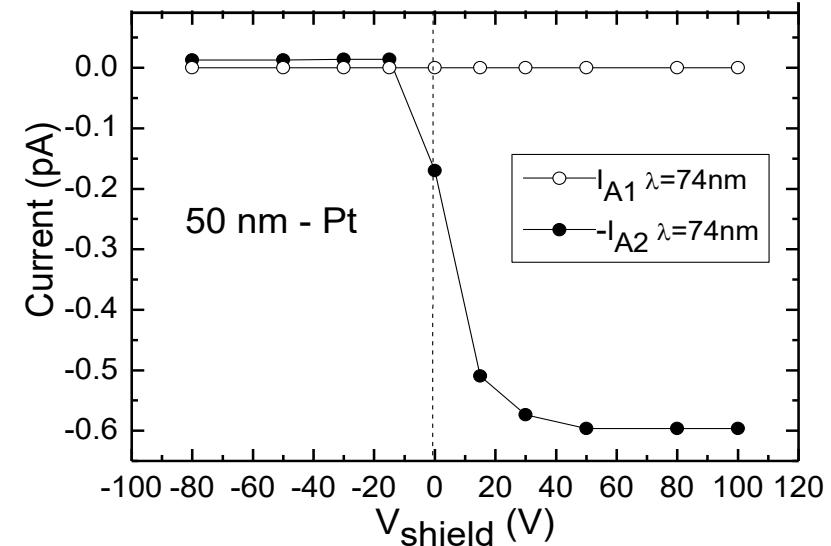
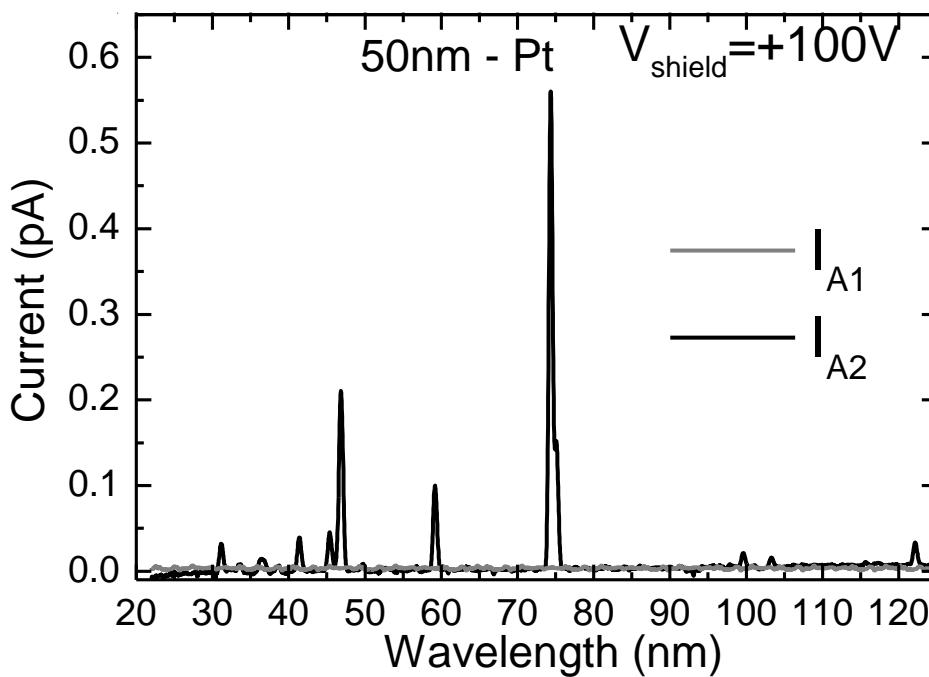
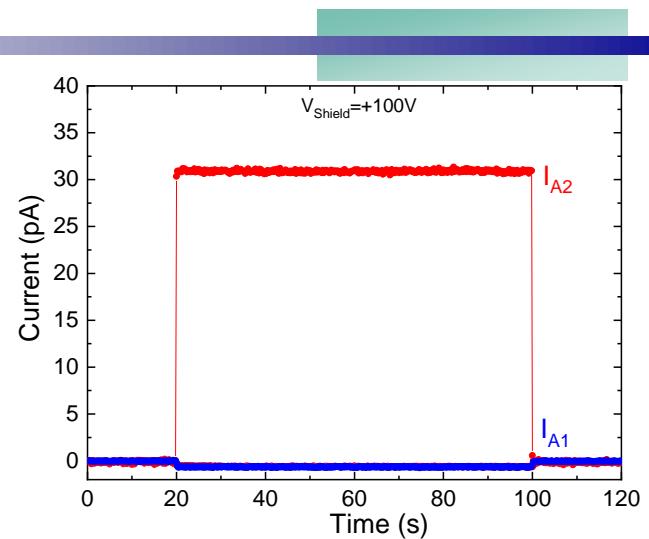
$I_e \sim 143 \% I_{ph}$  (@ $\lambda = 74 \text{ nm}$ )  
 $I_e \sim 8 \% I_{ph}$  (@ $\lambda = 30.4 \text{ nm}$ )



# Transverse configuration

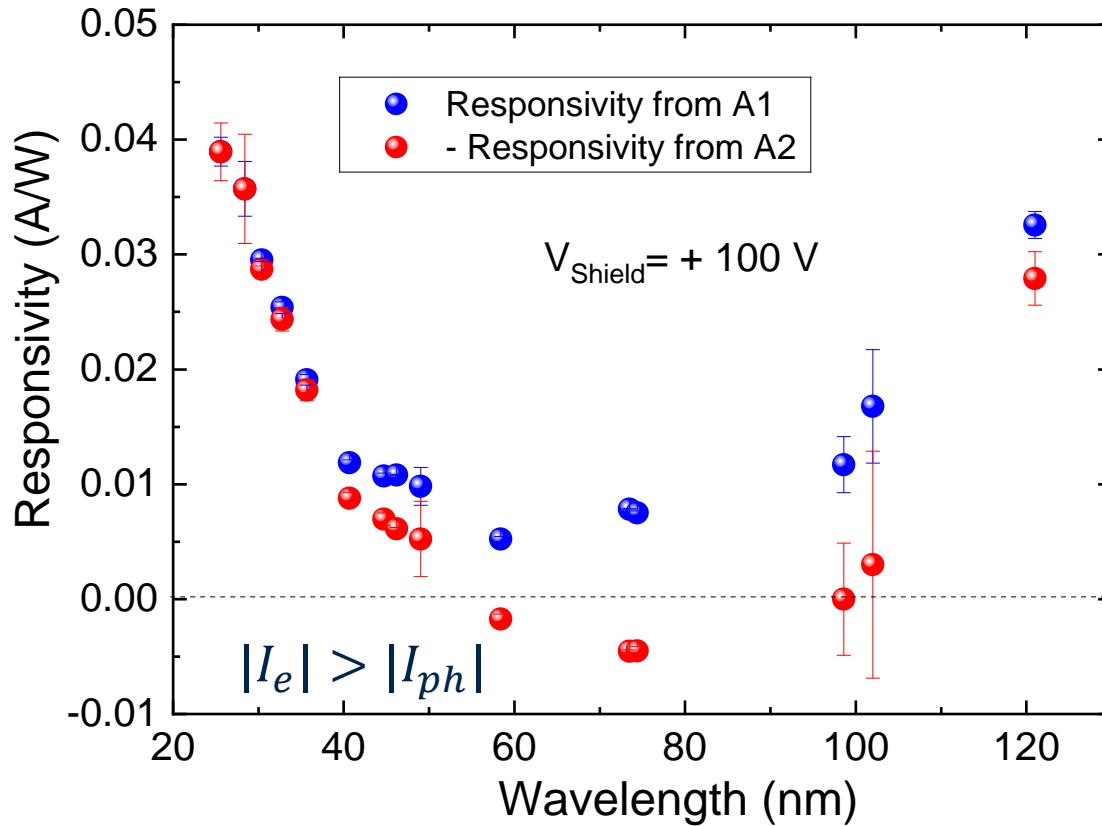


$$now I_{ph} = 0 \quad \begin{cases} I_{A_1} = 0 \\ I_{A_2} = I_e \end{cases}$$



# Transverse configuration: Responsivity

The spectral responsivity  $R$  is the current per unit of incident UV light power (A/W)



$$V_{shield} = +100 \text{ V}$$

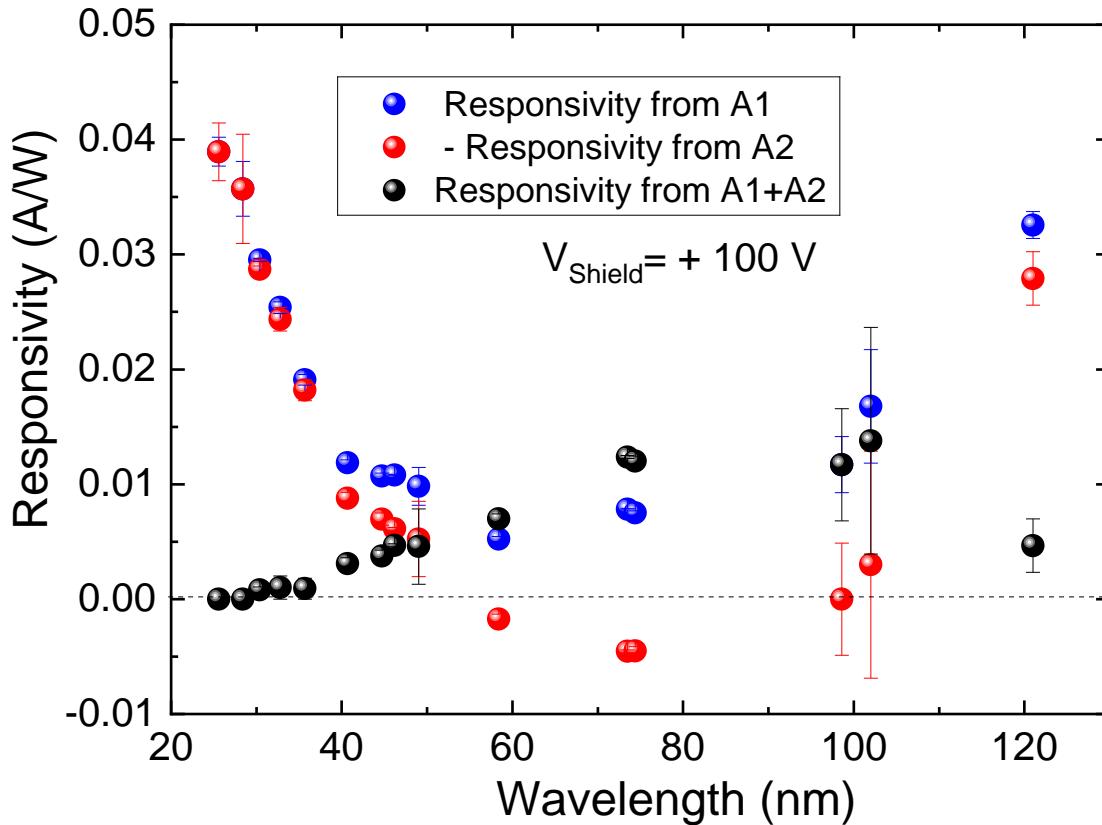
$$R_{A_1} = \frac{I_{A_1}}{W} = \frac{I_{ph}}{W} = R_{ph}$$

$$R_{A_2} = \frac{I_{A_2}}{W} = \frac{I_e - I_{ph}}{W}$$



# Transverse configuration: Responsivity

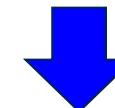
The spectral responsivity  $R$  is the current per unit of incident UV light power (A/W)



$$V_{shield} = +100 \text{ V}$$

$$R_{A_1} = \frac{I_{A_1}}{W} = \frac{I_{ph}}{W} = R_{ph}$$

$$R_{A_2} = \frac{I_{A_2}}{W} = \frac{I_e - I_{ph}}{W}$$

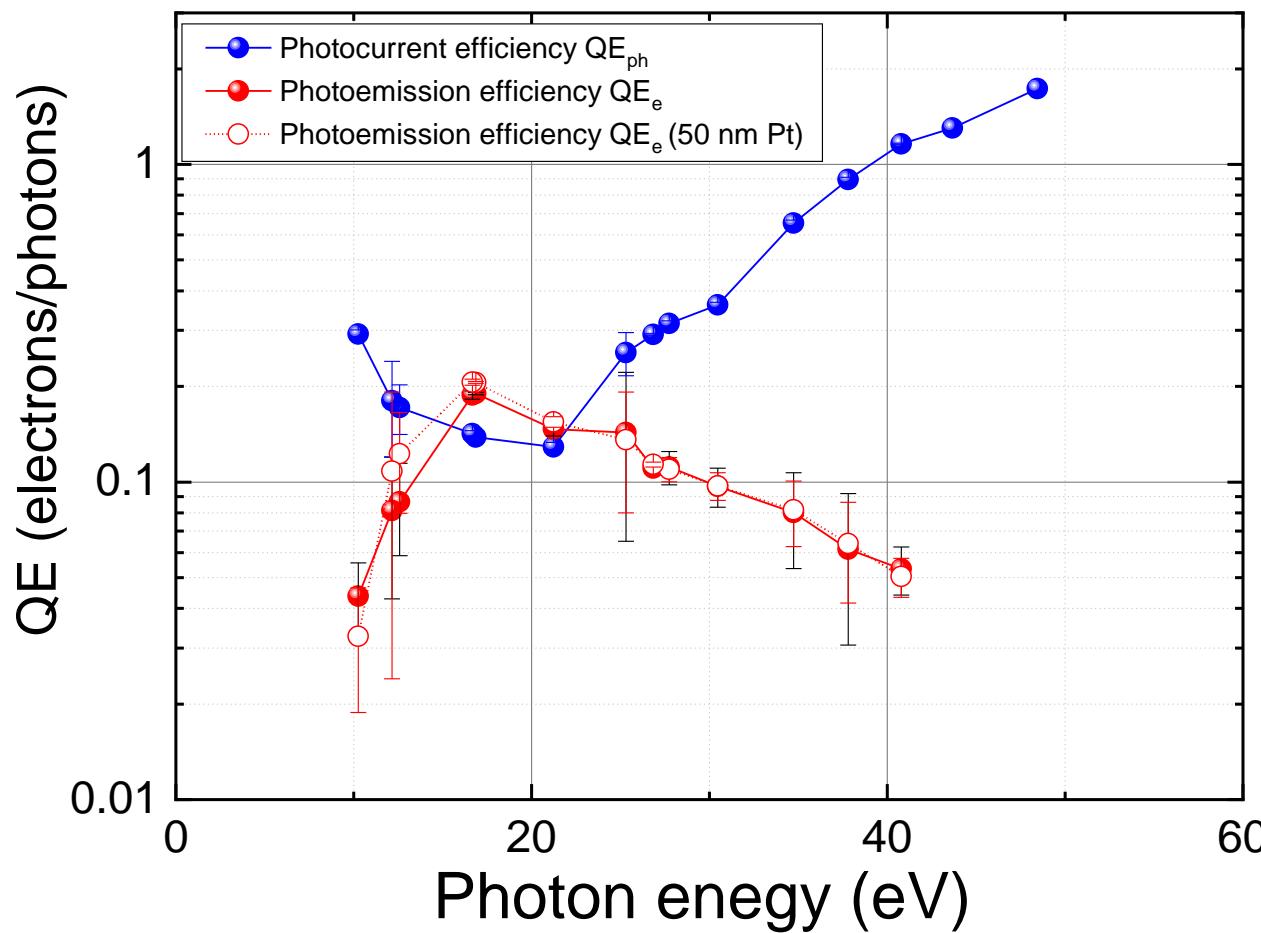


$$R_e = \frac{I_{A_1} + I_{A_2}}{W} = \frac{I_e}{W}$$



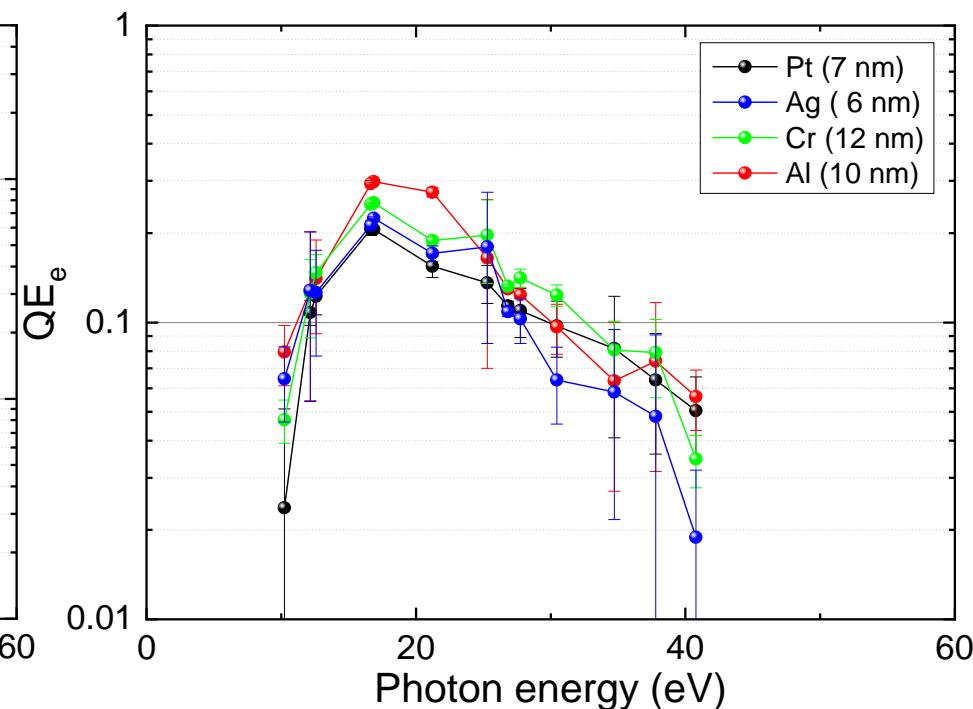
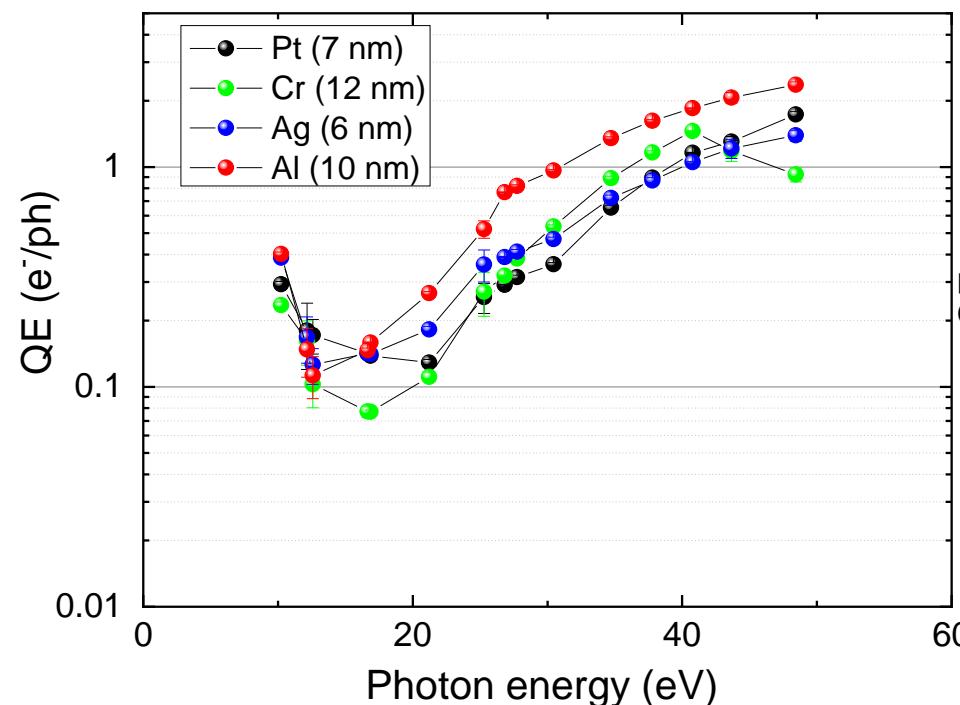
# Transverse configuration: Quantum efficiency

The quantum efficiency, defined by the number of photoelectrons per incident photons is given by  $QE = \frac{R}{\lambda} \times (1240 \text{ W} \cdot \frac{\text{nm}}{\text{A}})$

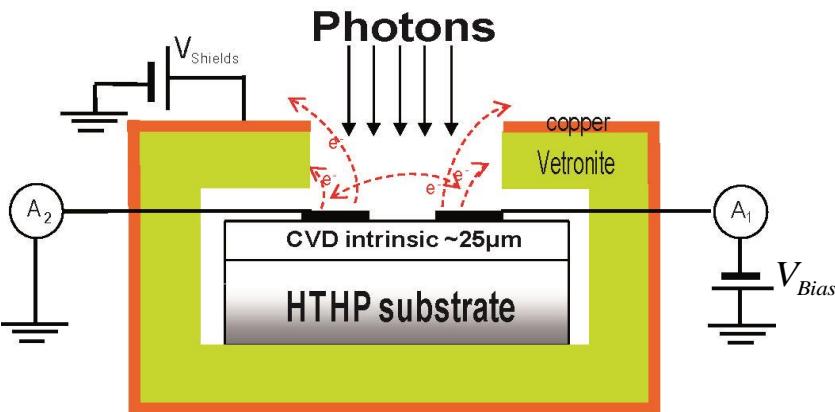


# *Influence of the metallic contact*

- ✓ Influence of the metallic contact on the performances of extreme UV diamond detector



# Planar configuration (interdigitated)



**Photoconductive detector in planar configuration with interdigitated electrodes**

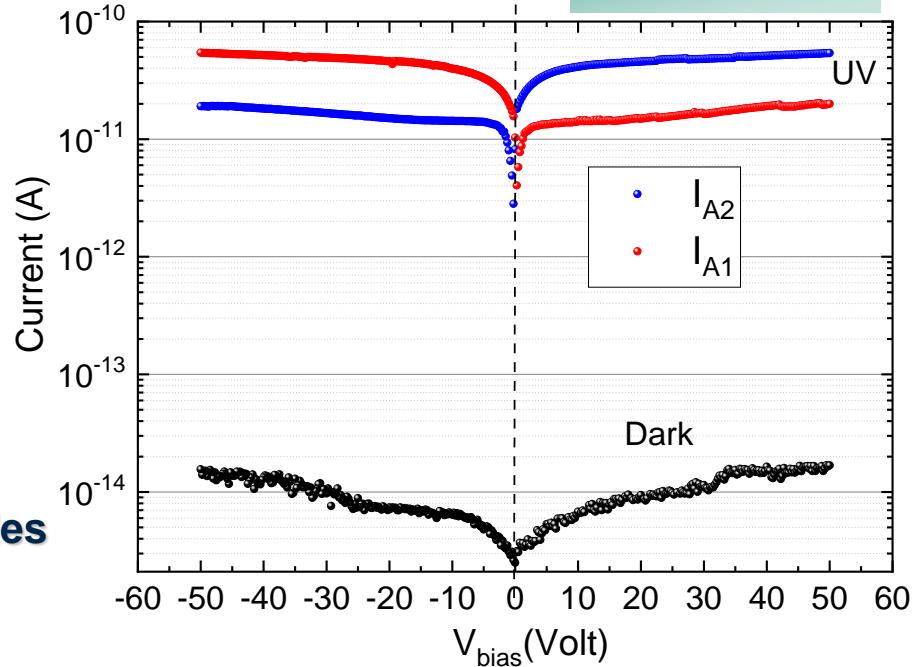
$$(I_{e_{1,2}}, I_{e_{2,1}} \ll I_{e_1}, I_{e_2})$$

$$|V_{shield}| \gg |V_{bias}| > 0, \quad V_{bias} > 0$$

$$\begin{cases} I_{A_1} = -I_{ph} + I_{e_1} \\ I_{A_2} = I_{ph} + I_{e_2} \end{cases}$$

$$|V_{shield}| \gg |V_{bias}| > 0, \quad V_{bias} < 0$$

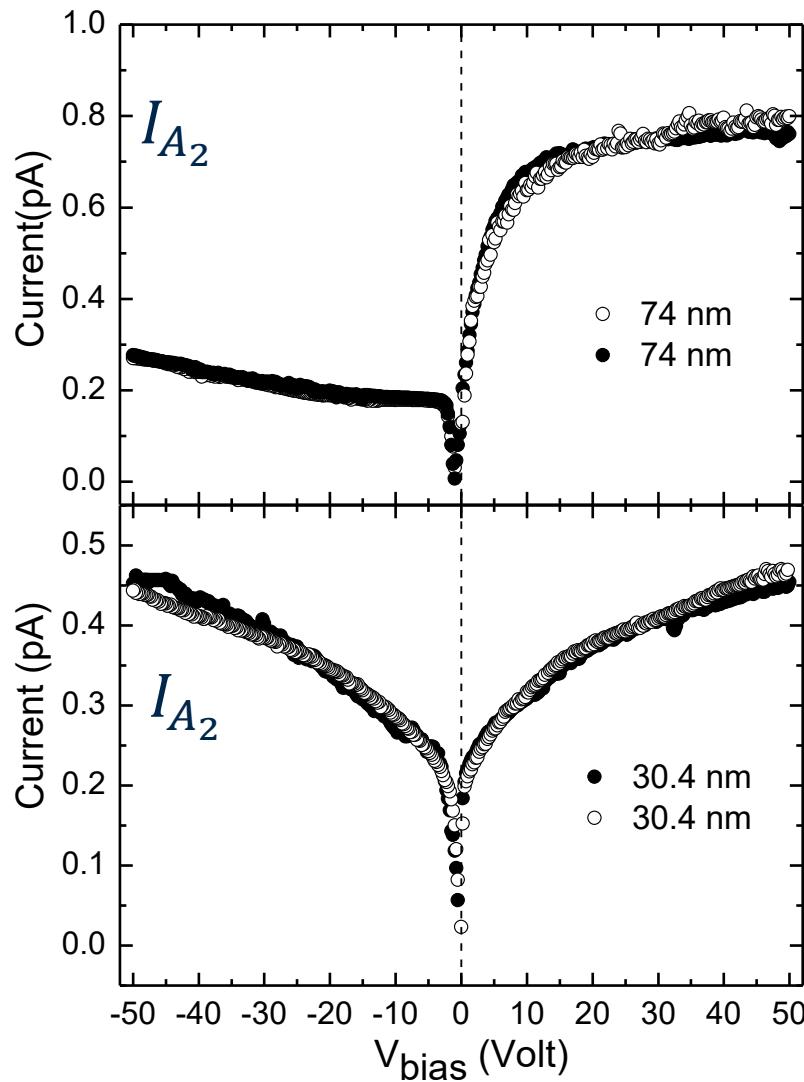
$$\begin{cases} I_{A_1} = I_{ph} + I_{e_1} \\ I_{A_2} = -I_{ph} + I_{e_2} \end{cases}$$



- I-V characteristics in dark and under broadband UV irradiation
- Due to the symmetric geometry of the device, a symmetric I-V curve would be expected.
- The photoresponse depends on detector bias applied (positive or negative).
- The asymmetry is due to photoelectrons emission.



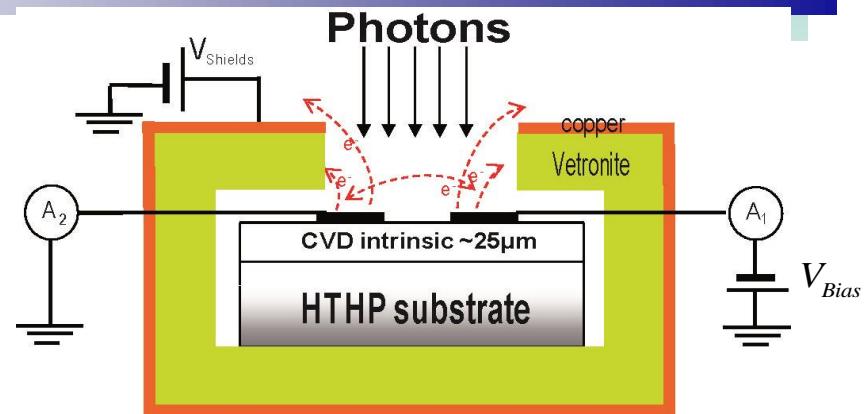
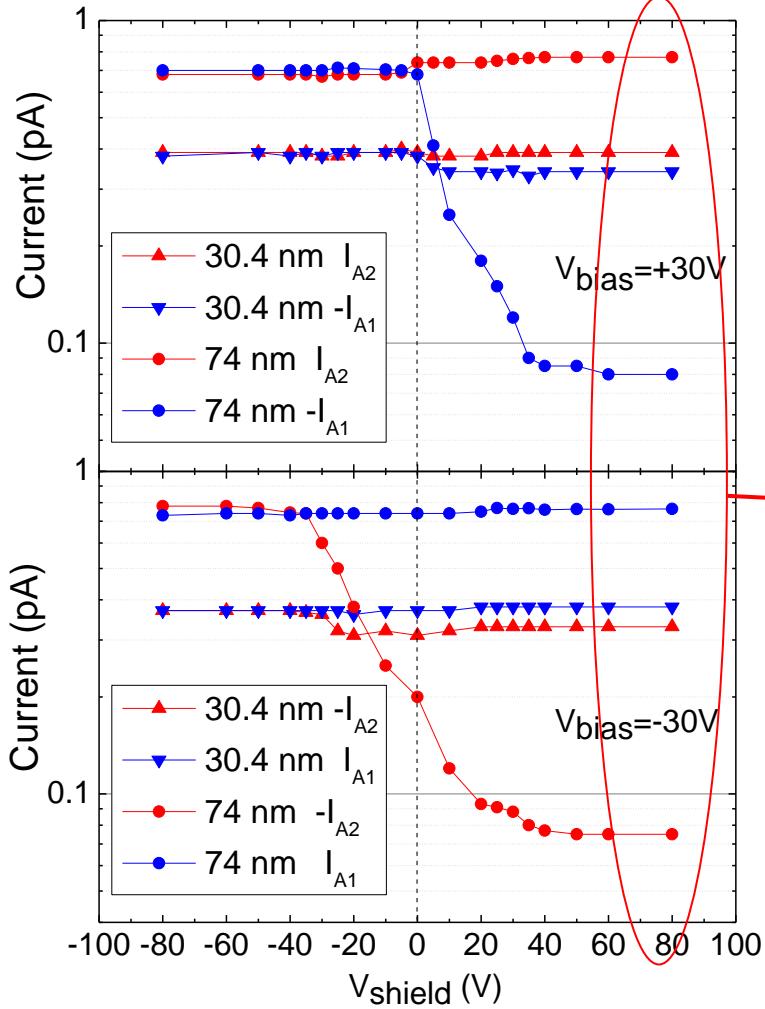
# Planar configuration: I-V characteristic



- Asymmetry depends on UV wavelengths
- Asymmetry more pronounced at 74 nm

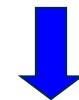


# Planar configuration (interdigitated)



**Photoconductive detector in planar configuration with interdigitated electrodes**

$$I_{e1} \sim I_{e2} \sim I_e$$



$$|V_{shield}| \gg |V_{bias}| > 0,$$

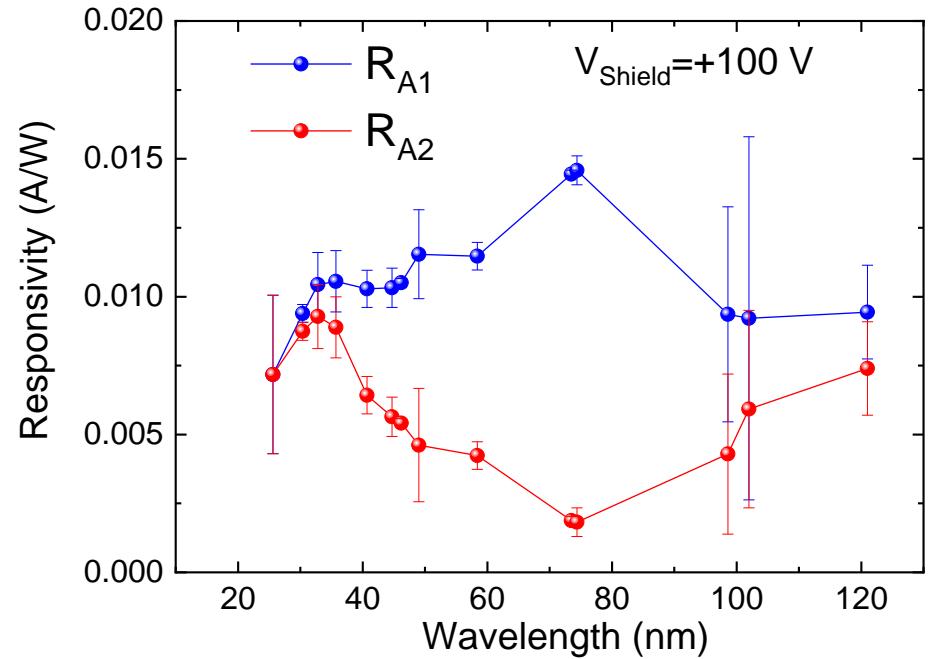
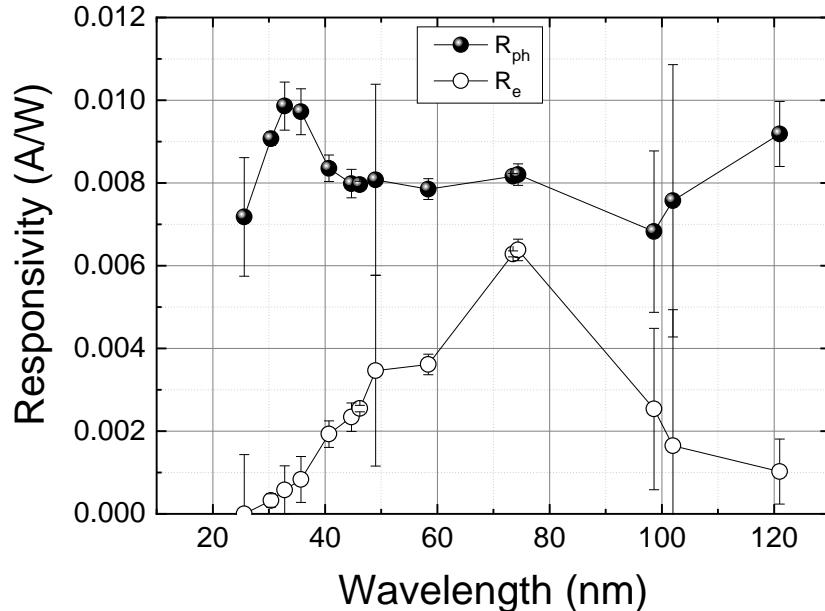
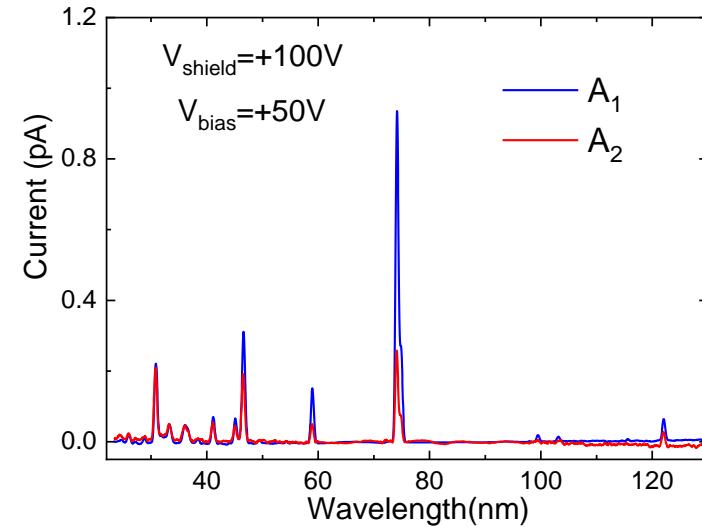
$$I_{ph} = \frac{I_{A_2} - I_{A_1}}{2}$$

$$I_e = \frac{I_{A_2} + I_{A_1}}{2}$$

$$I_e \sim 125\% I_e (@\lambda = 74 nm)$$



# Planar configuration: Responsivity



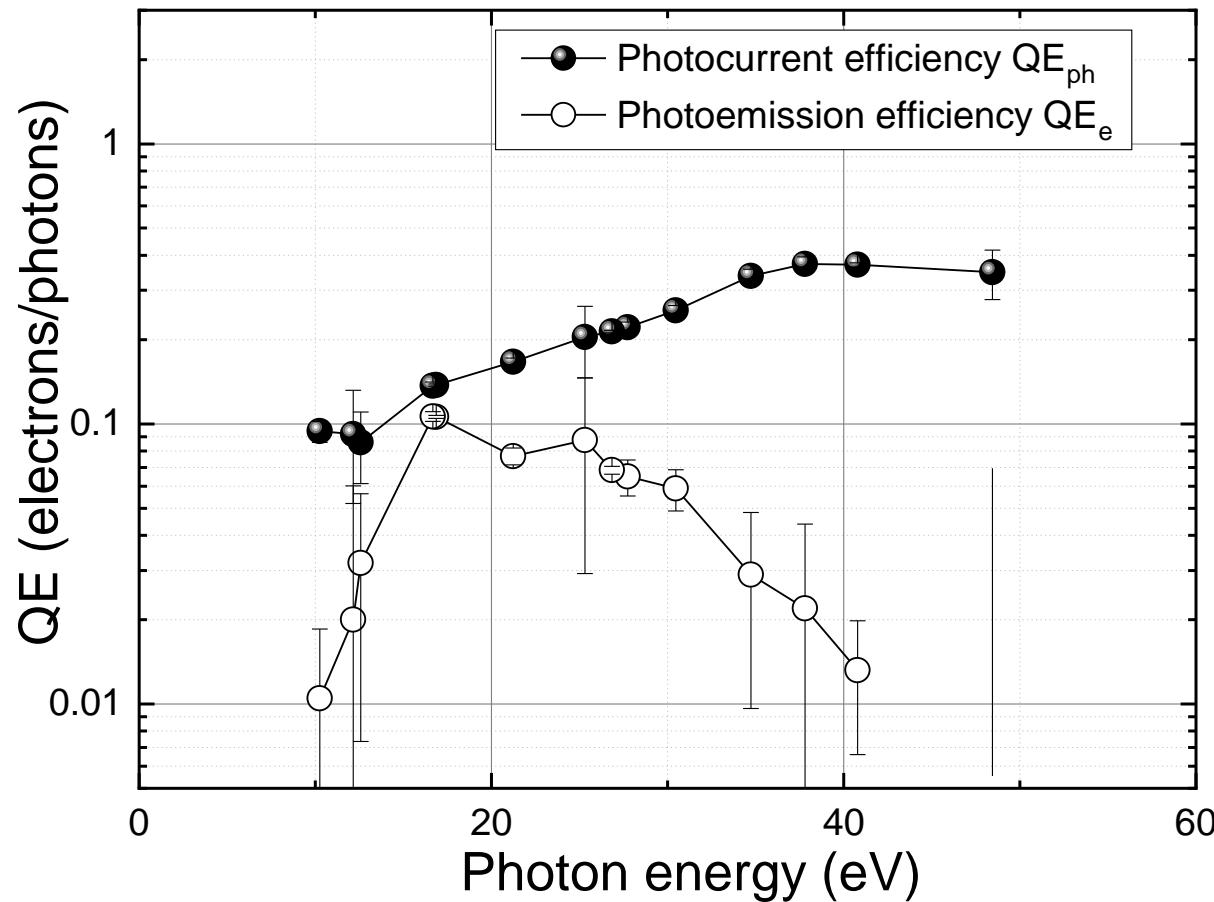
$$R_e = \frac{R_{A_2} + R_{A_1}}{2}$$

$$R_{ph} = \frac{R_{A_2} - R_{A_1}}{2}$$



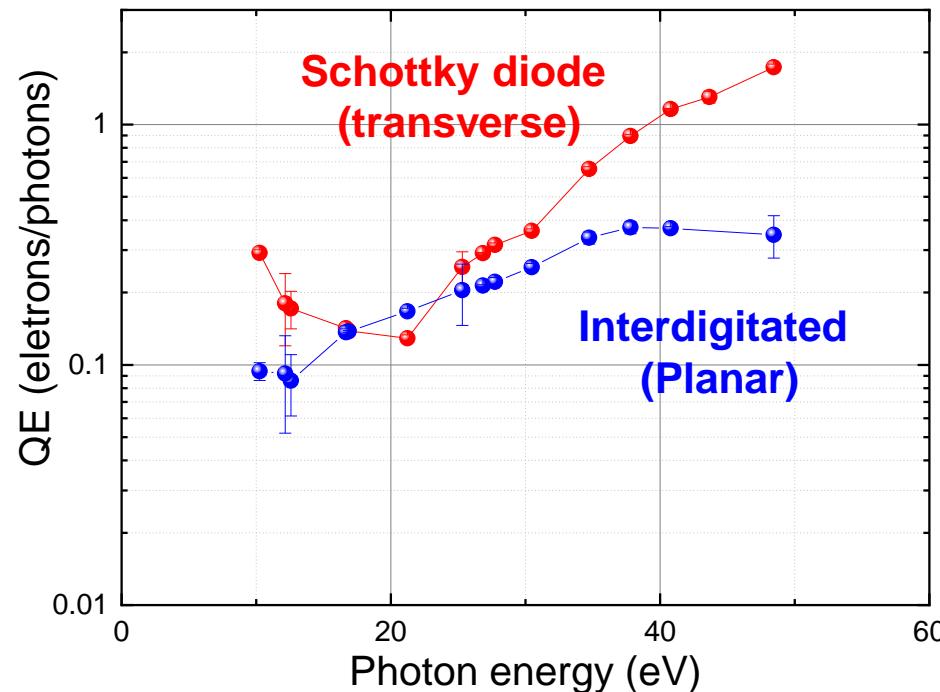
# Planar configuration: Quantum efficiency

The quantum efficiency, defined by the number of photoelectrons per incident photons is given by  $QE = \frac{R}{\lambda} \times (1240 \text{ W} \cdot \frac{\text{nm}}{\text{A}})$

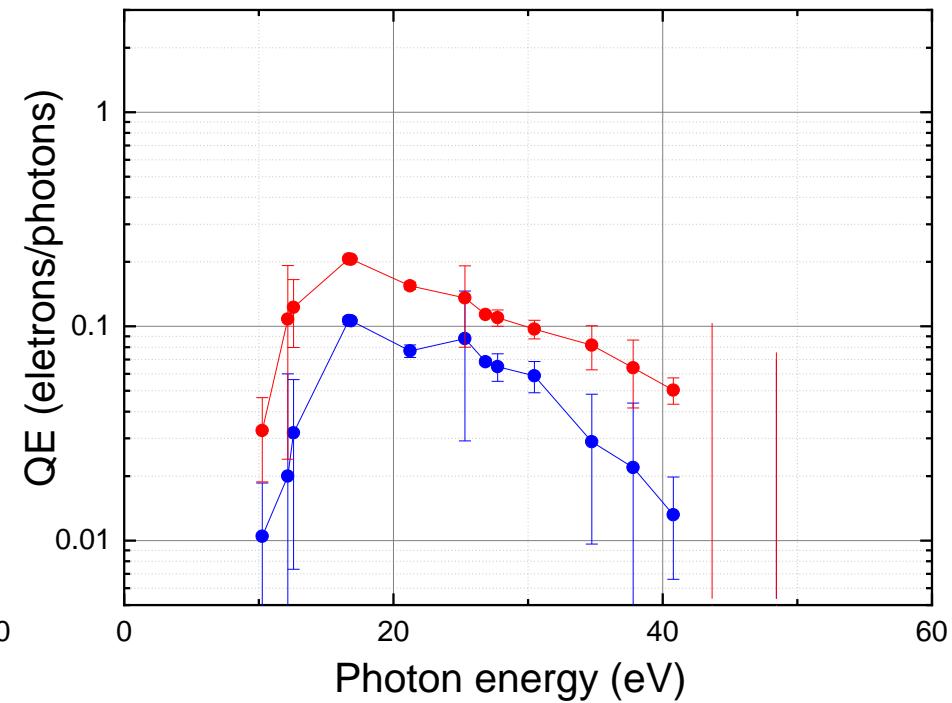


# Planar/transverse comparison

QE of diamond detectors



QE of secondary electron emission



✓ Higher efficiency of the Schottky diode device with respect to the one of the interdigitated contact sample was observed at the extremes of the investigated range (a factor 5 at 50 eV and a factor 3 at 10 eV). Similar efficiency was measured at intermediate photon energies.

✓ The quantum efficiency of photoelectric emission is high in the range 15-30 eV for both device and rapidly decreases towards the edge of the investigated region.



# Conclusions

- ✓ An experimental set-up was arranged to separate the internal photocurrent and secondary electrons current over the 20 – 120 nm spectral range
- ✓ Photoelectric current contribution to the total output current is not negligible being dominant at especially at intermediate wavelength (50-100 nm)
- ✓ The quantum efficiency of the photoelectric current depends on the set-up conditions (*i.e.* external electric field).
- ✓ In the transverse geometry detector, the contribution of secondary electrons can be easily excluded by using proper device housing and measuring the current from the boron doped diamond backing contact (absolute calibration), while in the planar geometry detector the response is inevitably affected to the contribution of photoemission current (the calibration is non reliability).





Thank you  
for your attention

